## **AMENDMENTS TO THE CLAIMS**

- 1. canceled
- 2. canceled
- 3. (currently amended) A process for the racemoselective preparation of silicon-bridged dialkyl-ansa-metallocenes of the formula (I):

$$R^2$$
 $T$ 
 $R^3$ 
 $Si \quad M^1R^1_2X_{x-2}$  (I)
 $T$ 

which comprises reacting a ligand starting compound of the formula (II):

with a transition metal dialkyl compound of the formula (III):

$$M^1X_xR^1_2*D_y$$
 (III), ·

## where

- M<sup>1</sup> is an element of group 4, 5 or 6 of the Periodic Table of the Elements;
- $R^1$  are identical  $C_1$ - $C_{20}$ -alkyl or  $C_7$ - $C_{40}$ -arylalkyl radicals;
- X are identical or different halogens;
- R<sup>2</sup> are identical or different C<sub>1</sub>-C<sub>40</sub> radicals;
- R<sup>3</sup> are identical or different C<sub>1</sub>-C<sub>40</sub> radicals;
- T is a divalent C<sub>1</sub>-C<sub>40</sub> group which together with the cyclopentadienyl ring forms a further saturated or unsaturated ring system which has a ring size of from 5 to 12 atoms, where T may contain the heteroatoms Si, Ge, N, P, O or S in the ring system fused onto the cyclopentadienyl ring;
- M<sup>2</sup> is Li, Na, K, MgCl, MgBr, MgI, Mg or Ca;
- D is an uncharged Lewis base-ligand;
- x is equal to the oxidation number of M<sup>1</sup> minus 2;
- y is from 0 to 2;

and

p is 1 in the case of doubly positively charged metal ions or 2 in the case of singly positively charged metal ions or metal ion fragments,

wherein the transition metal dialkyl compound of the formula (III) is produced at above –  $30^{\circ}$ C by combining a compound  $M^{1}X_{x+2}$  with from 2 to 2.5 equivalents of a compound  $R^{1}M^{3}$  in the presence of a ligand compound D, where

$$M^3$$
 is  $Li^+$ ,  $Na^+$ ,  $K^+$ ,  $MgCl^+$ ,  $MgBr^+$ ,  $MgI^+$ ,  $\frac{1}{2}$   $[Mg^{++}]$  or  $\frac{1}{2}$   $[Zn^{++}]$ .

- 4. canceled
- 5. canceled
- 6. (previously presented) The process as claimed in claim 3, wherein the reaction is carried out in an organic solvent or solvent mixture which comprises at least 10% by volume of an ether.
- 7. (canceled)

- 8. (canceled)
- 9. (currently amended) A process for the racemoselective preparation of silicon-bridged dialkyl-ansa-metallocenes of the formula (I):

$$R^{2}$$
 $R^{3}$ 
 $Si \quad M^{1}R^{1}_{2}X_{x-2}$  (I)

which comprises reacting a ligand starting compound of the formula (II):

with a transition metal dialkyl compound of the formula (III):

$$M^1X_xR^1_2*D_y$$
 (III),

where

 $R^2$  are identical or different  $C_1$ - $C_{40}$  radicals;

 $R^3$  are identical or different  $C_1$ - $C_{40}$  radicals;

M<sup>2</sup> is Li, Na, K, MgCl, MgBr, MgI, Mg or Ca;

- D is an uncharged Lewis base-ligand;
- x is equal to the oxidation number of M<sup>1</sup> minus 2;
- y is from 0 to 2;
- p is 1 in the case of doubly positively charged metal ions or 2 in the case of singly positively charged metal ions or metal ion fragments,
- T is a 1,3-butadiene-1,4-diyl group which may be unsubstituted or be substituted by from 1 to 4 radicals R<sup>4</sup>, where the two 1,3-butadiene-1,4-diyl groups may be different;
- R<sup>4</sup> are identical or different C<sub>1</sub>-C<sub>20</sub> radicals;
- M<sup>1</sup> is titanium, zirconium or hafnium;
- R<sup>1</sup> are identical C<sub>1</sub>-C<sub>5</sub>-alkyl or C<sub>7</sub>-C<sub>20</sub>-arylalkyl radicals; and
- X is halogen,

wherein the transition metal dialkyl compound of the formula (III) is produced at above –  $30^{\circ}$ C by combining a compound  $M^{1}X_{x+2}$  with from 2 to 2.5 equivalents of a compound  $R^{1}M^{3}$  in the presence of a ligand compound D, where

- 10. canceled
- 11. canceled